

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	6142	(oxygen or o2 or "o.sub.2") near5 ash\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 17:58
L2	559522	resist\$1 or photoresist\$1.	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 17:59
L3	331887	plasma	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 17:59
L4	540705	residue\$1	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L5	3882	1 same 2	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L6	10824	3 same 4	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L7	654	5 and 6	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L8	797820	gate\$1	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L9	73700	trench\$2	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00

L10	329	7 and (8 or 9)	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:00
L11	1329114	silicon or semiconduct\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:01
L12	328	10 and 11	US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB	OR	ON	2005/04/12 18:01